

# United States Patent and Trademark Office

UNITED STATES:DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

		<u></u>		
APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/658,126	09/08/2003	Julin Wan	02307Z-132710US	9694
20350 7	590 08/12/2005		EXAM	INER
TOWNSEND AND TOWNSEND AND CREW, LLP TWO EMBARCADERO CENTER			LOPEZ, CARLOS N	
EIGHTH FLO			ART UNIT	PAPER NUMBER
SAN FRANCI	ISCO, CA 94111-3834		1731	

DATE MAILED: 08/12/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)		
	10/658,126	WAN ET AL.		
Office Action Summary	Examiner	Art Unit		
	Carlos Lopez	1731		
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	correspondence address		
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).		
Status				
1) Responsive to communication(s) filed on <u>06 Ju</u>	ıne 2005.			
	action is non-final:			
☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
Disposition of Claims				
4) Claim(s) 1-40 is/are pending in the application. 4a) Of the above claim(s) 21-40 is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 1-20 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or Application Papers  9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the or	n from consideration. r election requirement. r. epted or b)□ objected to by the I drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).		
Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Ex	• • • • • • • • • • • • • • • • • • • •			
Priority under 35 U.S.C. § 119				
12) Acknowledgment is made of a claim for foreign  a) All b) Some * c) None of:  1. Certified copies of the priority documents  2. Certified copies of the priority documents  3. Copies of the certified copies of the priority application from the International Bureau  * See the attached detailed Office action for a list of	s have been received. s have been received in Applicati ity documents have been receive i (PCT Rule 17.2(a)).	on No ed in this National Stage		
Attachment(s)				
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:			

Application/Control Number: 10/658,126

Art Unit: 1731

#### DETAILED ACTION

### Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-20 are rejected under 35 U.S.C. 102(a) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Wan et al (Silicon Nitride-silicon Carbide Nancocomposites Fabricated by Electric-Field-Assisted Sintering). Wan et al discloses a method of making a dense silicon nitride and silicon carbide crystals. The method comprises activating a 200mesh (75 microns) powder of amorphous silicon nitride and silicone carbide by high-energy ball milling the powder (See Experimental Procedures). The activated powder is then sintered, deemed as the claimed consolidation step, by a plasma sintering system, electric-field-assisted sintering, which by definition passes an electric current through the powder mixture.

Application/Control Number: 10/658,126

Art Unit: 1731

Art Offic. 1731

Wan et al is silent disclosing the size of the powder after is activated by ball milling. However, in view that the powder already passes through a 75 micron sieve it is deemed as inherent or alternatively as obvious to a person of ordinary skill in the art to have particles within the claimed size range of 1 to 100 nanometers. Moreover, due to the ball milling of the 200 meshed powder, particles having 75 microns or less, the ball milling step done in activating the powder would further reduce the particle diameters and thus it would be inherent or at the least obvious to a person of ordinary skill in the art to have particles within the claimed range of 1 to 100 nanometers.

Additionally, Wan notes that composites with grain size well below 100nm can be achieved if the amount of yttria, a metal oxide densification aid, is less than 3% (See last paragraph of the left column in page 526). Hence, the claimed invention of having crystalline grains less than 100nm is clearly taught by Wan by using a metal oxide densification aid of less than 3%, which would encompass applicant's claimed range of at most 1%.

In regards to claims 2-6, Wan et al as noted above envisage the claimed parameters.

As for claims 7-8, the silicone carbon and nitrogen content is 28%, 43%, and 22% based on the nominal formula noted in the first paragraph of the right column in page 526.

As for claims 9-10; the claimed silazane pyrolized in nitrogen, an inert atmosphere, is disclosed in the first paragraph of the right column in page 526.

Art Unit: 1731

As for claims 11-14, the claimed pressure, current and temperature is disclosed in the first paragraph of the right column in page 526.

As for claims 16-17, in view that the claimed steps a and b are performed by Wan et al, it would be inherent or expected that the particles would have the claimed densities.

As for claim 18, see above.

As for claims 19-20, the balling milling is done with silicone nitride balls. The claimed impact rate and charge ratio are obvious process parameters adjusted to obtain the desired particle size and process time.

### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Carlos Lopez whose telephone number is 571.272.1193. The examiner can normally be reached on Mon.-Fri. 8am - 5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Steven Griffin can be reached on 571.272.1189. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Application/Control Number: 10/658,126 Page 5

Art Unit: 1731

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

CL